Special Issue

Advanced Processes Creating New Technologies in Tomorrow's Industry

Message from the Guest Editor

This Special Issue aims to bring together topics including, but not limited to:

- 3-D printing;
- Sensors;
- Coatings;
- Catalysts;
- New materials;
- Chemically processes for new technologies in industry:
- Monitoring 3D objects (e.g., from additive manufacturing);
- Artificial Intelligence for process monitoring;
- Fault diagnosis and troubleshooting;
- Integration of statistical process control and engineering process control;
- Bioinspired Processes;
- Micro-Nano Machining TiO2 Patterns;
- Photothermal Membrane of CuS/Polyacrylamide:
- Fabricating sub-100nm conducting polymer nanowires:
- Light-Trapping SERS Substrate with Regular;
- Fabrication of 3D biomimetic composite coating;
- Processes for robotics:
- Dynamic Processes;
- Industrial processes;
- Technical Processes.

Guest Editor

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Deadline for manuscript submissions

closed (23 October 2022)



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Message from the Editor-in-Chief

You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

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